

# Epitaxial growth and superconducting properties of thin-film PdFe/VN and VN/PdFe bilayers on MgO(001) substrates

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### Abstract

Single-layer vanadium nitride (VN) and bilayer Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> thin-film heterostructures for possible spintronics applications were synthesized on (001)-oriented single-crystalline magnesium oxide (MgO) substrates utilizing a fourchamber ultrahigh vacuum deposition and analysis system. The VN layers were reactively magnetron sputtered from a metallic vanadium target in Ar/N<sub>2</sub> plasma, while the Pd<sub>1-x</sub>Fe<sub>x</sub> layers were deposited by co-evaporation of metallic Pd and Fe pellets from calibrated effusion cells in a molecular beam epitaxy chamber. The VN stoichiometry and Pd<sub>1-x</sub>Fe<sub>x</sub> composition were controlled by X-ray photoelectron spectroscopy. In situ low-energy electron diffraction and ex situ X-ray diffraction show that the 30 nm thick single-layer VN as well as the double-layer VN(30 nm)/Pd<sub>0.92</sub>Fe<sub>0.08</sub>(12 nm) and Pd<sub>0.96</sub>Fe<sub>0.04</sub>(20 nm)/VN(30 nm) structures have grown cube-on-cube epitaxially. Electric resistance measurements demonstrate a metallic-type temperature dependence for the VN film with a small residual resistivity of 9  $\mu$ Ω·cm at 10 K, indicating high purity and structural quality of the film. The transition to the superconducting state was observed at 7.7 K for the VN film, at 7.2 K for the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN structure and at 6.1 K for the VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> structure with the critical temperature decreasing due to the proximity effect. Contrary to expectations, all transitions were very sharp with the width ranging from 25 mK for the VN film to 50 mK for the VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> structure. We propose epitaxial single-crystalline thin films of VN and heteroepitaxial Pd<sub>1-x</sub>Fe<sub>x</sub>/VN and VN/Pd<sub>1-x</sub>Fe<sub>x</sub> ( $x \le 0.08$ ) structures grown on MgO(001) as the materials of a choice for the improvement of superconducting magnetic random access memory characteristics.

### Introduction

Since its invention, rapid single-flux quantum (RSFQ) logic [1,2] based on superconducting digital electronics has been seriously considered as an alternative to semiconductor electronics for supercomputing applications [3-5]. Merging it with magnetism [6-8] has given a birth to superconducting spintronics [9,10]. The latter concept was implemented in the US Cryogenic Computing Complexity (C3) Program [11-13] with the goal "to demonstrate a small-scale computer based on superconducting logic and cryogenic memory that is energyefficient, scalable and able to solve interesting problems", opening prospects of reaching 100 PFLOPS/s with about 200 kW of electric power consumption including the cryogenic cooling. Niobium-based Josephson junction technology is currently implied to be used for the logics fabrication, however, hybrid Josephson junctions incorporating magnetic components are also considered for the mainframe computation components [9,14-19], and cache and main memories [8,20-25]. It is argued that the use of magnetic Josephson junctions in single-flux quantum electronics significantly reduces the number of junctions and interconnects in the circuits [26] and also has other important advantages such as wide operation margins and low bit-error rate [27]. The magnetic material has to be magnetically soft, tunable and weak in the sense of small spin-polarization of the conduction band [10,28]. The latter provides a large superconducting coherence length and hence bypasses a necessity to deposit flat, nanometer-thick continuous layers expected for strong elemental ferromagnets. A combination of niobium as a superconductor with a  $Pd_{1-x}Fe_x$  alloy as a soft and weak ferromagnet was considered as material of choice for superconducting magnetic random access memories (MRAM) [8,29,30]. However, no further developments towards a prototype using a  $Pd_{1-r}Fe_r$  alloy have been demonstrated. There are indications of non-homogeneous, nanoclustered magnetism in Pd<sub>0.99</sub>Fe<sub>0.01</sub> films grown on niobium [31], which may cause a shortening of the spin-memory length [32] and a reduction of the Josephson critical current.

In general, the metallic Nb lattice (body-centered cubic with  $a_{Nb} = 329.4$  pm) poorly matches that of the palladium-rich  $Pd_{1-x}Fe_x$  alloys (face-centered cubic with  $a_0 = 389$  pm). Therefore, a good crystallinity of the layer stack can hardly be expected. In the resulting polycrystalline films, crystallite boundaries and crystal lattice imperfections can lead to the segregation of iron impurities and to nanoclustering of the alloy. Following the development of a way to grow single-crystalline, magnetically homogeneous epitaxial  $Pd_{1-x}Fe_x$  films on MgO(001) single-crystalline substrates [33], we propose fully epitaxial  $Pd_{1-x}Fe_x/VN$  and  $VN/Pd_{1-x}Fe_x$  ( $x \le 0.08$ ) building blocks as an alternative choice for superconducting MRAM materials, in which vanadium nitride (VN) serves as the supercon-

ductor. The magnetic anisotropies of a 20 nm thick  $Pd_{0.96}Fe_{0.04}$  film of the first-generation epitaxial sample of VN/Pd<sub>0.96</sub>Fe<sub>0.04</sub> on MgO(001) were studied by using a ferromagnetic resonance technique in [34].

## Results and Discussion Sample preparation

Single-crystalline MgO(001) (henceforth designated MgO) epipolished substrates (CRYSTAL GmbH, Germany) with a size of  $10 \times 5 \times 0.5$  mm<sup>3</sup> were annealed at 800 °C for 5 min in the ultrahigh vacuum (UHV) molecular beam epitaxy (MBE) chamber with a residual pressure below  $10^{-10}$  mbar (SPECS, Germany). Then, depending on the desired structure, either the Pd<sub>1-x</sub>Fe<sub>x</sub> alloy layer or the VN layer was deposited. The Pd<sub>1-x</sub>Fe<sub>x</sub> layers were grown by means of UHV MBE following a three-step procedure described in detail in [33]. Metallic Pd (99.95% purity, EVOCHEM GmbH, Germany) and Fe (99.97% purity, ChemPur GmbH, Germany) were co-evaporated from the pre-calibrated high-temperature effusion cells to obtain the desired Pd<sub>1-x</sub>Fe<sub>x</sub> composition.

Vanadium nitride layers were synthesized by using reactive DC magnetron sputtering (MS) in the UHV chamber with a base pressure of  $p \le 5 \times 10^{-10}$  mbar (BESTEC, Germany). During this process, the substrate had a temperature of 500 °C. A mixture of high-purity (99.9999%) argon (Ar) from a gas chromatography purification system and high-purity (99.9999%) nitrogen (N<sub>2</sub>) at a composition of Ar/N<sub>2</sub> = 60:40 was used as plasma gas for the reactive synthesis of VN. During the deposition process, the pressure of the Ar/N<sub>2</sub> gas mixture in the chamber was automatically kept at  $6 \times 10^{-3}$  mbar. A metallic vanadium disk of 99.95% purity (GIRMET Ltd, Russia) was used as a target. The magnetron power was 50 W, the distance between the target and the substrate was 20 cm, and the deposition rate was 0.2 nm/min.

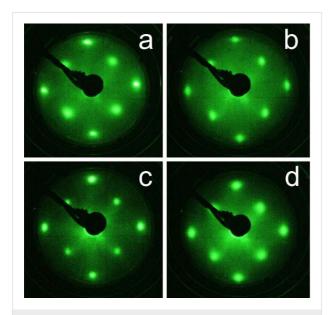
To grow heterostructures, the samples on the molybdenum holder were moved without breaking vacuum via the UHV transfer line between the MBE and MS deposition chambers as well as the analysis chamber (SPECS, Germany).

To perform a comparative study allowing to see only the proximity effect of the ferromagnetic layer on the properties of the superconducting VN layer, the latter was deposited in one run for all studied samples. To do this, we mounted two  $10 \times 5 \times 0.5$  mm<sup>3</sup> MgO substrates close and parallel to each other on the sample holder and used a system of two orthogonal shutters in the MBE chamber. After depositing a 20 nm thick Pd<sub>0.96</sub>Fe<sub>0.04</sub> layer onto one substrate (with the second being blocked by the shutter), the sample holder was moved to

the magnetron chamber, and a 30 nm layer of VN was grown on both substrates. Then, the holder was moved back to the MBE chamber, and a 12 nm thick  $Pd_{0.92}Fe_{0.08}$  layer was deposited to a half of both samples using the second shutter. The thicknesses of the  $Pd_{1-x}Fe_x$  layers were adjusted to possess identical magnetic moments. In situ tests of crystallinity, VN stoichiometry and resulting composition of  $Pd_{1-x}Fe_x$  were taken at each deposition step using low-energy electron diffraction (LEED) and X-ray photoelectron spectroscopy (XPS). Finally, all structures were capped with 10 nm layer of undoped Si by magnetron sputtering to prevent sample deterioration. Thus, a VN film and stacks of  $Pd_{0.96}Fe_{0.04}/VN$  and  $VN/Pd_{0.92}Fe_{0.08}$  (the first component in a stack being directly deposited to MgO) have been obtained with the identical properties of the VN layer in each sample.

#### Crystallinity and epitaxial growth

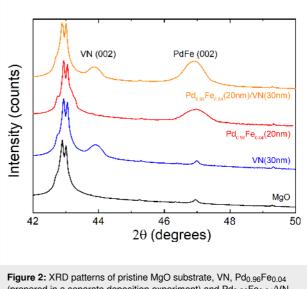
The crystallinity and the epitaxial growth of the thin films were examined in situ by using LEED (SPECS, Germany). LEED images were taken of the pristine MgO(001) substrate after annealing (Figure 1a), after the deposition of VN(30 nm) on MgO (Figure 1b), after the deposition of Pd<sub>0.92</sub>Fe<sub>0.08</sub> on VN (Figure 1c) and after the deposition of VN on Pd<sub>0.96</sub>Fe<sub>0.04</sub> (Figure 1d). Figure 1b indicates that the individual VN thin film has grown cube-on-cube epitaxially (for an individual Pd<sub>1-x</sub>Fe<sub>x</sub> film see the full crystallinity analysis in [33]). Figure 1c, ashows that the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> heterostructures are pass-through epitaxial. This is, first of all, due to the good lattice match between MgO, VN and Pd:



**Figure 1:** LEED patterns of (a) pristine MgO annealed at 800 °C, (b) the VN film, (c) the VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> and (d) Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN structures on the MgO(001) substrate. All patterns were taken at an electron energy of 140 eV.

 $a_{MgO} = 421.2 \text{ pm}, a_{VN} = 413.7 \text{ pm} [35] \text{ and } a_{Pd} = 389.1 \text{ pm}.$ Thus, the lattice mismatch between MgO and VN is only about 1.7%, and between Pd and VN it is as small as 5.95%.

The in situ LEED analysis was corroborated with ex situ X-ray diffraction (XRD, BRUKER D8, Germany) measurements using Cu K $\alpha$  ( $\lambda$  = 1.5418 Å) radiation in the Bragg–Brentano geometry with a scanning rate of 0.002°/s in the 2 $\theta$  range from 17° to 82° and a step width of 0.0153°. Room-temperature XRD patterns of the pristine MgO(001) substrate, the VN thin film on MgO, Pd<sub>0.96</sub>Fe<sub>0.04</sub> on MgO and the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN heterostructure are shown in Figure 2. The  $\theta$ –2 $\theta$  scans clearly indicate the single-crystalline structure of the VN and Pd<sub>0.96</sub>Fe<sub>0.04</sub> thin films and of the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN heterostructures. The (002) reflex of the MgO substrate, the (002) reflex of the VN film (30 nm), and the (002) reflex of the Pd<sub>0.96</sub>Fe<sub>0.04</sub> (20 nm) film can be easily identified.



(prepared in a separate deposition experiment) and  $\mathsf{Pd}_{0.96}\mathsf{Fe}_{0.04}/\mathsf{VN}.$ 

The significant peak broadening of the diffraction maxima of VN and Pd<sub>0.96</sub>Fe<sub>0.04</sub> is primarily due to small coherent scattering range  $\tau$  along the normal to the film plane (Scherrer broadening); XRD data with accounting for the instrument function [33] yields estimates of  $\tau \approx 22.0$  nm for Pd<sub>0.96</sub>Fe<sub>0.04</sub>,  $\tau \approx 12.6$  nm for Pd<sub>0.92</sub>Fe<sub>0.08</sub> and  $\tau \approx 30.4$  nm for VN, which agree quantitatively with the film thickness values  $d(Pd_{0.96}Fe_{0.04}) \approx 21.5$  nm,  $d(Pd_{0.92}Fe_{0.08}) \approx 12.5$  nm and  $d(VN) \approx 29.8$  nm, respectively, measured ex situ with a BRUKER DektakXT stylus profiler by using the shadow mask method. Thus, LEED and XRD measurements confirm that the VN thin film and the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> heterostructures have grown cube-on-cube epitaxially and that all samples are single crystalline.

The stoichiometry and chemical composition of the VN and the  $Pd_{1-x}Fe_x$  layers were analyzed in situ using XPS. The measurements were carried out in the UHV analysis chamber (base pressure  $p < 3 \times 10^{-10}$  mbar) equipped with a Mg K $\alpha$  X-ray source operated at 12.5 kV and 250 W, and a Phoibos-150 hemispherical energy analyzer (all from SPECS, Germany). Figure 3a,b shows the XPS spectra of the as-deposited VN/ Pd\_{0.92}Fe\_{0.08} thin film heterostructure. The binding energies of the Fe 2p\_{1/2}, Fe 2p\_{3/2}, and Pd 3d\_{3/2} and Pd 3d\_{5/2} states are 721.0, 707.7, and 340.2 and 335.0 eV, respectively, which agrees well with literature data [33,36].

Figure 3c,d shows the XPS spectra of the VN thin film on MgO. The binding energies of the V  $2p_{1/2}$ , V  $2p_{3/2}$  and N 1s states are 521.1, 513.6 and 397.4 eV, respectively, which are very close to that given in the literature for crystalline VN [37,38]. The presence of a characteristic satellite at a binding energy of ca. 515 eV is a fingerprint of V in a nitride compound [37]. The chemical composition of the as-grown VN and Pd<sub>1-x</sub>Fe<sub>x</sub> layers was analyzed with the CasaXPS software [39]. According to the XPS data, the stoichiometry of synthesized layers was Pd/Fe = 96:4, V/N = 52.5:47.5 and Pd/Fe = 92:8, respectively, with an accuracy of ±0.5%. Neither impurities nor surface contaminations were detected (compare with [40]). All recorded high-resolution XPS spectra of VN and Pd<sub>1-x</sub>Fe<sub>x</sub> films were calibrative.

ed to the binding energies of crystalline VN at 513.6 eV and of metallic Pd at 335.0 eV [33,37], respectively.

Magnetic moment measurements shown in Figure 4 confirm the composition of  $Pd_{0.96}Fe_{0.04}$  and  $Pd_{0.92}Fe_{0.08}$  through the ferromagnetic transition temperature  $T_{\rm C} \approx 125$  K and  $T_{\rm C} \approx 240$  K, respectively [41].

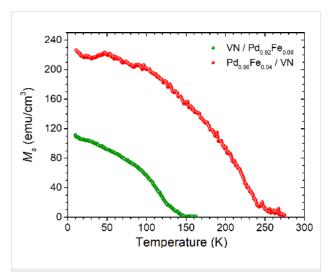
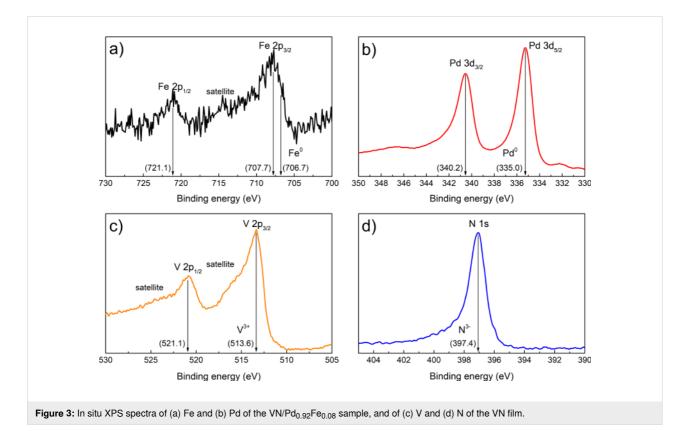


Figure 4: Saturation magnetization  $M_{\rm s}(T)$  as a function of the temperature of the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN (green symbols) and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> (red symbols) heterostructures measured in a magnetic field of 200 Oe.



#### Temperature dependence of resistance and superconducting transition

A physical property measurement system (QUANTUM DESIGN PPMS-9, USA) was used for studying the temperature dependence of the electrical resistance of the VN thin films and Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> heterostructures in the temperature range of 4.2–300 K. A four-probe resistance measurement scheme was used. Figure 5 shows the measurement results as a function of the temperature for the epitaxial VN film and the heteroepitaxial Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> samples. Table 1 contains the data on the residual resistance ratio RRR (i.e., the ratio of room temperature resistance,  $R_{300K}$ , to the resistance at 10 K,  $R_{10K}$ ), the superconducting transition temperature (mid-transition criterion) and the width of the superconducting transition (10–90% criterion) for the VN thin film and the heterostructures with Pd<sub>1-x</sub>Fe<sub>x</sub>.

<b>Table 1:</b> Electrical and superconducting properties of the VN film and the $Pd_{0.96}Fe_{0.04}/VN$ and $VN/Pd_{0.92}Fe_{0.08}$ heteroepitaxial structures on MgO(001).				
structure	RRR	<i>Т</i> <sub>с</sub> (К)	Δ7 <sub>c</sub> (mK)	
VN(30 nm)	5.2	7.7	25	
Pd <sub>0.96</sub> Fe <sub>0.04</sub> (20 nm)/VN(30 nm)	3.5	7.2	37	
VN(30 nm)/Pd <sub>0.92</sub> Fe <sub>0.08</sub> (12 nm)	2.6	6.1	50	

The temperature dependence of the resistance of the VN thin film is of metallic type and exhibits two temperature intervals, one above 250 K and another one in the range of 80–180 K, of quasi-linear temperature dependence with different temperature coefficients of resistivity (TCR), i.e.,  $9.7 \times 10^{-3} \Omega/K$  and

2.1 × 10<sup>-2</sup>  $\Omega$ /K, respectively, marked by red straight lines over the green line in Figure 5a. It is similar to the *R*(*T*) behavior of VN/MgO(011) samples in [42], which was explained by a change in the electron/phonon scattering amplitude upon the structural phase transition from cubic to tetragonal at  $T_s = 250$  K. Below 50 K the *R*(*T*) dependence saturates approaching the residual resistance originating, in general, from impurities and imperfections. Further cooling results in the phase transition to the superconducting state as it is shown in Figure 5b. The RRR value of 5.2 and the room-temperature resistivity of 42.5  $\mu$ Ω·cm for the 30 nm thick VN film are among the best values obtained to date [42-45], indicating the high purity and structural quality of our VN film.

The superconducting transition temperature  $T_c$  of the VN film is 7.7 K (see Table 1), which is well above the temperature of liquid helium, LHeT = 4.2 K. Figure 5b shows a very sharp resistive transition at T = 7.7 K with a small width of 25 mK, which is quite remarkable compared to an elemental niobium film of the same (30 nm) thickness deposited in the same chamber and under vacuum conditions ( $\Delta T_c$  [Nb(30 nm)]) = 10–23 mK).

Combining the VN film into a heterostructure with a palladiumrich  $Pd_{1-x}Fe_x$  alloy leads to a lowering of  $T_c$  because of the proximity effect [28]. This may shift the material operation temperature close to or even below the LHe*T*. With the iron content *x* in  $Pd_{1-x}Fe_x$  alloy below 0.08 its magnetic properties meet all the requirements for the F-layer in superconducting spintronic S/F/S-type structures, i.e., it is a weak ferromagnet with a low coercive field [41]. It is important that magnetic properties of epitaxial  $Pd_{1-x}Fe_x$  films are precisely controlled with the iron content *x* [41], and a perfect cube-on-cube epitaxy is realized with either the MgO(001) substrate or with the supercon-

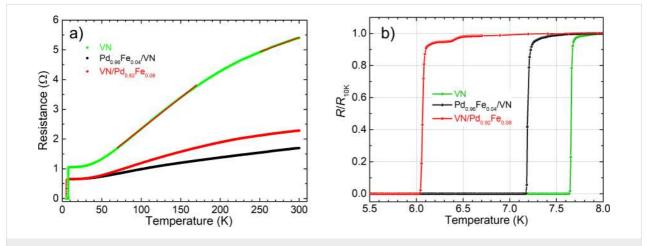


Figure 5: Temperature dependence of the electrical resistance of the VN film and the Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> heterostructures: (a) full temperature range, (b) low-temperature region.

ducting VN layers in any sequence. Figure 5b shows that 12 nm thick layer of Pd<sub>0.92</sub>Fe<sub>0.08</sub> alloy adjacent to the 30 nm VN film lowers  $T_c$  from 7.7 K to 6.1 K, which is well above the LHeT. Moreover, Figure 5b demonstrates that the transition stays sharp: the maximum  $\Delta T_c$  increases only to 50 mK, and there is no tail towards lower temperatures. Also, there is a room to optimize the superconducting parameters of the VN film towards an increase in T<sub>c</sub> by about 1 K [43,44]. In our opinion, the results hint at a possible use of heteroepitaxial combinations of nitrides as superconductors and palladium-rich Pd<sub>1-r</sub>Fe<sub>r</sub> alloys as weak tunable ferromagnets to improve the operation characteristics of superconductor-ferromagnet-insulator heterojunctions for superconducting spintronics applications. For example, cubic superconducting  $MoN_x$ , which is a Josephson junction technology material [4,5,46], exhibits a good epitaxial match with  $Pd_{1-x}Fe_x$  alloys,  $a_0(MoN) = 416.3$  pm.

#### Conclusion

Fully epitaxial single-crystalline thin films of VN and heteroepitaxial structures of Pd<sub>1-x</sub>Fe<sub>x</sub>/VN and VN/Pd<sub>1-x</sub>Fe<sub>x</sub> (x = 0.04, 0.08, respectively) were grown on single-crystalline MgO(001) substrates using a combination of UHV molecular beam epitaxy and magnetron sputtering. The obtained 30 nm thick VN films exhibit a sharp superconducting transition with  $T_c = 7.7$  K and  $\Delta T_c = 25$  mK. The heteroepitaxial Pd<sub>0.96</sub>Fe<sub>0.04</sub>/VN and VN/Pd<sub>0.92</sub>Fe<sub>0.08</sub> structures reveal a superconductor-ferromagnet proximity suppression of the transition temperature to  $T_c = 6.1$  K. This is, however, well above the liquid helium temperature of 4.2 K and, therefore, suitable for superconducting spintronics. The superconducting transition stays sharp with a somewhat larger width of  $\Delta T_c = 50$  mK. Moreover, there is no resistive tail towards lower temperatures. These results, in our opinion, indicate that fully epitaxial Pd<sub>1-x</sub>Fe<sub>x</sub>/VN and VN/Pd<sub>1-x</sub>Fe<sub>x</sub> thin film stacks can be considered as building blocks for superconducting spintronics elements.

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